

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/825,372		04/16/2004	Howard E. Rhodes	M4065.0105/P105-C	8394	
24998	7590	09/29/2005		EXAMINER		
210112121		RO MORIN & OS	NGUYEN, TUAN H			
	2101 L Street, NW Washington, DC 20037				PAPER NUMBER	
vv asimigron	200		2813			

DATE MAILED: 09/29/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

				SY			
		Application No.	Applicant(s)	<i>)</i> /			
		10/825,372	RHODES, HOWAR	RHODES, HOWARD E.			
	Office Action Summary	Examiner	Art Unit				
		Tuan H. Nguyen	2813				
Period fo	The MAILING DATE of this communication ap	ppears on the cover sheet v	vith the correspondence add	ress			
A SH WHIC - Exter after - If NO - Failu Any r	ORTENED STATUTORY PERIOD FOR REPORTENED STATUTORY PERIOD FOR REPORTED IN A CONTROL OF THE MAILING IN THE MAILIN	DATE OF THIS COMMUN 1.136(a). In no event, however, may a d will apply and will expire SIX (6) MC ate, cause the application to become a	ICATION.  a reply be timely filed  DNTHS from the mailing date of this con ABANDONED (35 U.S.C. § 133).				
Status							
1) 又	Responsive to communication(s) filed on 21.	July 2005.					
<i>'</i> —		is action is non-final.					
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dispositi	on of Claims						
5)□ 6)⊠ 7)□	Claim(s) 200-209 is/are pending in the applic 4a) Of the above claim(s) 124-137 and 170-1 Claim(s) is/are allowed. Claim(s) 200-209 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/	<u>88</u> is/are withdrawn from o	consideration.	<b>.</b>			
Applicati	on Papers						
•	The specification is objected to by the Examir						
10)	<del>-</del>	ccepted or b) objected to					
44)	Applicant may not request that any objection to the Replacement drawing sheet(s) including the corre	ection is required if the drawin	g(s) is objected to. See 37 CFF				
11)	The oath or declaration is objected to by the E	Examiner. Note the attache	ed Office Action or form PTC	J-152.			
Priority ι	ınder 35 U.S.C. § 119						
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of: <ol> <li>Certified copies of the priority documents have been received.</li> <li>Certified copies of the priority documents have been received in Application No</li> <li>Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>							
2) Notice 3) Information Paper	t(s) te of References Cited (PTO-892) te of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/06 or No(s)/Mail Date	Paper No	Summary (PTO-413) o(s)/Mail Date Informal Patent Application (PTO- 	152)			

Application/Control Number: 10/825,372

Art Unit: 2813

## **DETAILED ACTION**

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 200-204, 206, 209 are rejected under 35 U.S.C. 102(b) as being anticipated by Yamada et al..

Yamada, figs. 4-5 and related text on col. 4-6 discloses the claimed method for forming a photosensor comprising excavating a trench by anisotropically etching the semiconductor substrate (fig. 5(e)-5(f)); performing a first and second implantation into the vertical internal surface region and the bottom surface region of the trench at first and second implantation angle (fig. 5(g)-5(j) and related text in col. 5-6, paragraph (3)-(5)).

With respect to claim 201, col. 6, paragraph (5) teaches the second implantation to the inside of the trench in a rotating manner that includes orthogonal angle to the first implantation.

With respect to claims 203, 204, col. 6, lines 12-14 discloses the formation of silicon dioxide above the vertical internal surface region.

With respect to claim 206, col. 5, line 62 discloses the use of PSG film 309 above the vertical internal surface region.

Application/Control Number: 10/825,372

Art Unit: 2813

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 205, 207, 208 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamada et al. in view of the admitted prior art.

Yamada, figs. 4-5 and related text on col. 4-6 discloses the claimed method for forming a photosensor except the use of BPSG or BSG as a passivation layer and CMP for a subsequent step of forming contact and wiring.

However, in paragraphs bridging pages 16-17, applicant clearly admitted that BPSG, PSG, or BSG are well-known material for use in passivating the device and CMP is a well-known process for planarizing in the final steps of forming contact and wiring.

Accordingly, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have used the well-known BSP or BPSG material and CMP process in forming contact and wiring as admitted as prior art in Yamada et al. process for completing the device as in the instant claimed invention.

#### Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Kobayashi teaches the step of implanting ions into the vertical

surface and bottom regions of the trench to form region 7 as shown in fig. 4D. Also note that the first and second implantations, and first and second implantation angles could be considered as a single implantation at the same angle.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

### Response to Arguments

Applicant's arguments with respect to claims 200-209 have been considered but are most in view of the new ground(s) of rejection.

Application/Control Number: 10/825,372 Page 5

Art Unit: 2813

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 571-272-1694. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tuan H. Nguyén Primary Examiner Art Unit 2813

man H. Nguyen